The documentation and process conversion measures necessary to comply with this revision shall be completed by 23 October 2001.

INCH-POUND

MIL-PRF-19500/512E 23 July 2001 SUPERSEDING MIL-PRF-19500/512D 14 July 2000

PERFORMANCE SPECIFICATION

SEMICONDUCTOR DEVICE, TRANSISTOR, PNP, SILICON, SWITCHING TYPES 2N4029, 2N4033, 2N4033UA, 2N4033UB, JAN, JANTX, JANTXV, JANS AND JANKC2N4033 AND JANHC2N4033

This specification is approved for use by all Departments and Agencies of the Department of Defense.

1. SCOPE

- 1.1 <u>Scope</u>. This specification covers the performance requirements for PNP silicon transistors designed for use in high speed switching and driver applications. Four levels of product assurance are provided for each encapsulated device type and two levels of product assurance for each unencapsulated specified as in MIL-PRF-19500.
- 1.2 <u>Physical dimensions</u>. See figures 1 (TO-18), figure 2 (TO-39), figure 3 and figure 4 (surface mount)) and figure 5 (JANKC and JANHC) herein.

1.3 Maximum ratings.

P _T (1) T _A = +25°C	P _T (2) T _A = +25°C	P _T (3) T _A = +25°C	P _T (1) T _A = +25°C	V _{СВО}	V _{CEO}	V _{EBO}	Ic	T _{OP} and T _{STG}
2N4029	2N4033	2N4033UA	2N4033UB					
W	w	<u>w</u>	<u>w</u>	V dc	V dc	<u>V dc</u>	A dc	<u>°C</u>
0.5	0.8	0.65	0.5	80	80	5.0	1.0	-65 to +200

R _Ð JA	R _Ð JA	$R_{ hetaJA}$
2N4029 2N4033UB	2N4033	2N4033UA
<u>°C/W</u>	<u>°C/W</u>	<u>°C/W</u>
325	175	210

- (1) Derate linearly 3.08 mW/ $^{\circ}$ C above $T_A = +37.5 ^{\circ}$ C.
- (2) Derate linearly 5.7 mW/°C above T_A = +60°C.
- (3) Derate linearly 4.76 mW/ $^{\circ}$ C above $T_A = +63.5 ^{\circ}$ C.

Beneficial comments (recommendations, additions, deletions) and any pertinent data which may be of use in improving this document should be addressed to: Defense Supply Center, Columbus, ATTN: DSCC/VAC, Post Office Box 3990, Columbus, OH 43216-5000, by using the Standardization Document Improvement Proposal (DD Form 1426) appearing at the end of this document or by letter.

AMSC N/A FSC 5961

DISTRIBUTION STATEMENT A. Approved for public release; distribution is unlimited.

1.4 Primary electrical characteristics at $T_A = +25^{\circ}C$.

Limits	h _{FE1}	h _{FE2}	h _{FE3}	h _{FE4}	h _{fe}
Lillins	$V_{CE} = 5.0 \text{ V dc}$ $I_{C} = 100 \mu\text{A dc}$	$V_{CE} = 5.0 \text{ V dc}$ $I_{C} = 100 \text{ mA dc}$	$V_{CE} = 5.0 \text{ V dc}$ $I_{C} = 500 \text{ mA dc}$	$V_{CE} = 5.0 \text{ V dc}$ $I_{C} = 1.0 \text{ A dc}$	$f = 100 \text{ MHz}$ $V_{CE} = 10 \text{ V dc}$ $I_{C} = 50 \text{ mA dc}$
Min Max	50	100 300	70	25	1.5 6.0

Limits	$V_{CE(SAT)2}$ $I_C = 500 \text{ mA dc}$ $I_B = 50 \text{ mA dc}$	C_{obo} $V_{CB} = 10 \text{ V dc}$ $I_{E} = 0$ $100 \text{ kHz} \le f \le 1 \text{ MHz}$	t _d	t _r	t _s	t _f
Min	V dc	рF	<u>ns</u>	<u>ns</u>	<u>ns</u>	<u>ns</u>
Max	0.5	20	15	25	175	35

2. APPLICABLE DOCUMENTS

2.1 <u>General</u>. The documents listed in this section are specified in sections 3 and 4 of this specification. This section does not include documents cited in other sections of this specification or recommended for additional information or as examples. While every effort has been made to ensure the completeness of this list, document users are cautioned that they must meet all specified requirements documents cited in sections 3 and 4 of this specification, whether or not they are listed.

2.2 Government documents.

2.2.1 <u>Specifications, standards, and handbooks</u>. The following specifications, standards, and handbooks form a part of this document to the extent specified herein. Unless otherwise specified, the issues of these documents are those listed in the issue of the Department of Defense Index of Specifications and Standards (DoDISS) and supplement thereto, cited in the solicitation (see 6.2).

SPECIFICATION

DEPARTMENT OF DEFENSE

MIL-PRF-19500 - Semiconductor Devices, General Specification for.

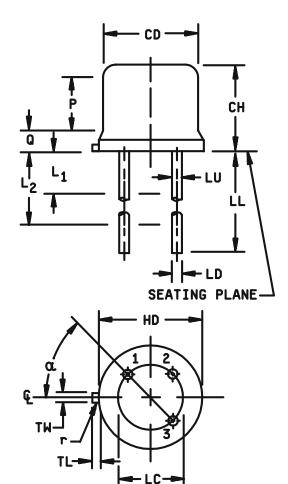
STANDARD

DEPARTMENT OF DEFENSE

MIL-STD-750 - Test Methods for Semiconductor Devices.

(Unless otherwise indicated, copies of the above specifications, standards, and handbooks are available from the Document Automation and Production Services (DAPS), Building 4D (DPM-DODSSP), 700 Robbins Avenue, Philadelphia, PA 19111-5094.)

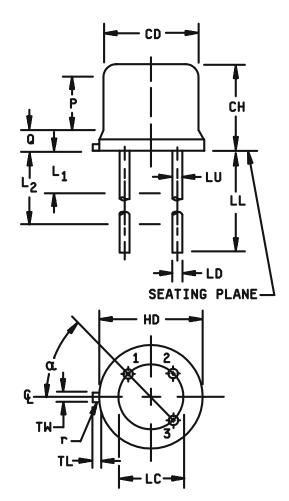
	Dime		nsions			
Symbol	Inc	hes	Millimeters		Notes	
	Min	Max	Min	Max		
CD	.178	.195	4.52	4.95		
СН	.170	.210	4.32	5.34		
HD	.209	.230	5.31	5.84		
LC	.100) TP	2.54	1 TP	6	
LD	.016	.021	0.41	0.53	7, 8	
LL	.500	.750	12.70	19.05	7, 8, 12	
LU	.016	.019	0.41	0.48	7, 8	
L ₁		.050		1.27	7. 8	
L_2	.250		6.35		7, 8	
Q		.040		1.02	5	
TL	.028	.048	0.71	1.22	3, 4	
TW	.036	.046	0.91	1.17	3	
r		.010		0.18	10	
Р	.100		2.54			
α	45°TP		45°	TP	6	



- 1. Dimension are in inches.
- 2. Metric equivalents are given for general information only.
- 3. Beyond r (radius) maximum, TW shall be held for a minimum length of .011 (0.28 mm).
- 4. Dimension TL measured from maximum HD.
- 5. Body contour optional within zone defined by HD, CD, and Q.
- 6. Leads at gauge plane .054 +.001 -.000 inch (1.37 +0.03 -0.00 mm) below seating plane shall be within .007 inch (0.18 mm) radius of true position (TP) at maximum material condition (MMC) relative to tab at MMC. The device may be measured by direct methods.
- 7. Dimension LU applies between L1 and L2. Dimension LD applies between L2 and minimum. Diameter is uncontrolled in L1 and beyond LL minimum.
- 8. All three leads.
- 9. The collector shall be internally connected to the case.
- 10. Dimension r (radius) applies to both inside corners of tab.
- 11. In accordance with ANSI Y14.5M, diameters are equivalent to θx symbology.
- 12. For "L" suffix devices, dimension LL is 1.50 (38.10 mm) minimum, 1.75 (19.05 mm) maximum.

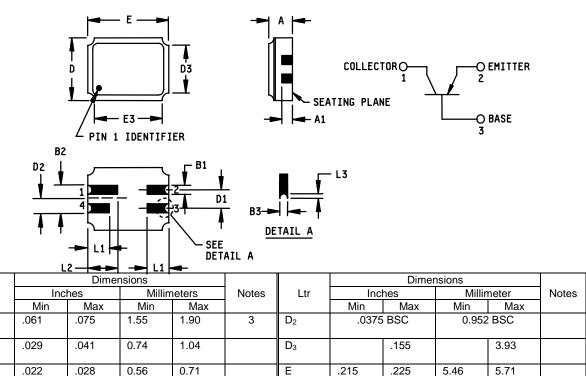
FIGURE 1. Physical dimensions (type 2N4029) (TO - 18).

		Dime	nsions		
Symbol	Incl	hes	Millin	neters	Notes
	Min	Max	Min	Max	
CD	.305	.335	7.75	8.51	
СН	.240	.260	6.10	6.60	
HD	.335	.370	8.51	9.40	
LC	.200) TP	5.0	8 TP	6
LD	.016	.021	0.41	0.53	7, 8
LL	.500	.750	12.70	19.05	7, 8, 12
LU	.016	.019	0.41	0.48	7, 8
L ₁		.050		1.27	7, 8
L ₂	.250		6.35		7, 8
Q		.050		1.27	5
TL	.029	.045	0.74	1.14	3, 4
TW	.028	.034	0.71	0.86	3
r		.010		0.18	10
Р	.100		2.54		
α	45°TP		45	°TP	6



- 1. Dimension are in inches.
- 2. Metric equivalents are given for general information only.
- 3. Beyond r (radius) maximum, TW shall be held for a minimum length of .011 (0.28 mm).
- 4. Dimension TL measured from maximum HD.
- 5. Body contour optional within zone defined by HD, CD, and Q.
- 6. Leads at gauge plane .054 +.001 -.000 inch (1.37 +0.03 -0.00 mm) below seating plane shall be within .007 inch (0.18 mm) radius of true position (TP) at maximum material condition (MMC) relative to tab at MMC. The device may be measured by direct methods.
- 7. Dimension LU applies between L1 and L2. Dimension LD applies between L2 and minimum. Diameter is uncontrolled in L1 and beyond LL minimum.
- 8. All three leads.
- 9. The collector shall be internally connected to the case.
- 10. Dimension r (radius) applies to both inside corners of tab.
- 11. In accordance with ANSI Y14.5M, diameters are equivalent to θx symbology.
- 12. For "L" suffix devices, dimension LL is 1.50 (38.10 mm) minimum, 1.75 (19.05 mm) maximum.

FIGURE 2. Physical dimensions (type 2N4033) (TO - 39).



.225

.048

.088

.007

0.81

1.83

0.08

.032

.072

.003

5.71

1.22

2.23

0.18

5

NOTES:

Ltr

Α

A₁

Βı

 B_2

 B_3

D

 D_1

1. Dimensions are in inches.

.075 REF

.022

.155

.055

.006

.145

.045

2. Metric equivalents are given for general information only.

1.91 REF

0.56

3.93

1.39

0.15

3.68

1.14

3. Dimension "A" controls the overall package thickness. When a window lid is used, dimension "A" must increase by a minimum of .010 inch (0.254 mm) and a maximum of .040 inch (1.020 mm).

E₃

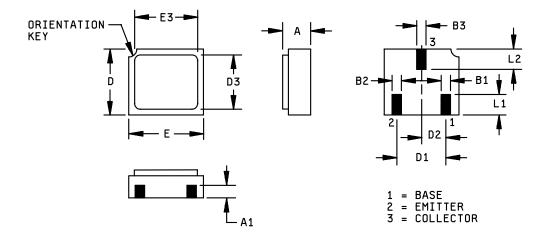
 L_1

L₂

 L_3

- 4. The corner shape (square, notch, radius, etc.) may vary at the manufacturer's option, from that shown on the drawing.
- 5. Dimensions "B3" minimum and "L3" minimum and the appropriately castellation length define an unobstructed three-dimensional space traversing all of the ceramic layers in which a castellation was designed. (Castellations are required on bottom two layers, optional on top ceramic layer.) Dimension "B3" maximum and "L3" maximum define the maximum width and depth of the castellation at any point on its surface. Measurement of these dimensions may be made prior to solder dipping.

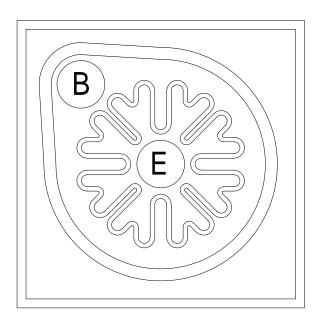
FIGURE 3. Physical dimensions, surface mount (UA version).



Ltr		Dimensions			Notes
	Inc	hes	Millin	neters	
	Min.	Max.	Min.	Max.	
Α	.046	.056	0.97	1.42	
A1	.017	.035	0.43	0.89	
B1	.016	.024	0.41	0.61	3
D	.085	.108	2.41	2.74	
D1	.071	.079	1.81	2.01	
D2	.035	.039	0.89	0.99	
D3					
Е	.115	.128	2.82	3.25	
E3					
L1	.022	.038	0.56	0.96	4

- 1. Dimensions are in inches.
- Metric equivalents are given for general information only.
 Dimensions B2 and B3 are identical to B1
- 4. Dimension L2 is identical to L1.

FIGURE 4. Physical dimensions, surface mount UB version.



Die size: Die thickness:

.030 x .030 inch (0.762 x 0.762 mm). .008 ±.0016 inch (0.2032 ±0.04064 mm). .005 inch diameter (0.127 mm). .005 inch diameter (0.127 mm). Gold, 6500 ± 1950 Ang. Aluminum, 22500 ±2500 Ang. Base pad: Emitter pad: Back metal: Top metal:

Back side: Collector.

Glassivation: SiO₂, 7500 ± 1500 Ang.

FIGURE 5. JANHC and JANKC (A-version) die dimensions.

2.3 <u>Order of precedence</u>. In the event of a conflict between the text of this document and the references cited herein, the text of this document takes precedence. Nothing in this document, however, supersedes applicable laws and regulations unless a specific exemption has been obtained.

3. REQUIREMENTS

- 3.1 <u>General</u>. The requirements for acquiring the product described herein shall consist of this document and MIL-PRF-19500.
- 3.2 <u>Qualification</u>. Devices furnished under this specification shall be products that are manufactured by a manufacturer authorized by the qualifying activity for listing on the applicable qualified manufacturer's list (QML) before contract award (see 4.2 and 6.3).
- 3.3 <u>Abbreviations, symbols, and definitions</u>. Abbreviations, symbols, and definitions used herein shall be as specified in MIL-PRF-19500.
- 3.4 <u>Interface and physical dimensions</u>. The interface and physical dimensions shall be as specified in MIL-PRF-19500 and on figures 1, 2, 3, 4, and 5 herein.
- 3.4.1 <u>Lead finish</u>. Lead finish shall be solderable in accordance with MIL-PRF-19500, MIL-STD-750 and herein. Where a choice of lead finish is desired, it shall be specified in the acquisition document (see 6.2).
 - 3.5 Marking. Marking shall be in accordance with MIL-PRF-19500.
- 3.6 <u>Electrical performance characteristics</u>. Unless otherwise specified herein, the electrical performance characterics are as specified in 1.3, 1.4 and table I herein.
- 3.7 <u>Electrical test requirements</u>. The electrical test requirements shall be the subgroups specified in 4.4.2 and 4.4.3 herein.
- 3.8 Workmanship. Semiconductor devices shall be processed in such a manner as to be uniform in quality and shall be free from other defects that will affect life, serviceability, or appearance.

4. VERIFICATION

- 4.1 Classification of inspections. The inspection requirements specified herein are classified as follows:
 - a. Qualification inspection (see 4.2).
 - b. Screening (see 4.3).
 - c. Conformance inspection (see 4.4).
- 4.2 Qualification inspection. Qualification inspection shall be in accordance with MIL-PRF-19500 and as specified herein.

4.3 <u>Screening (JANS, JANTX and JANTXV levels only)</u>. Screening shall be in accordance with table IV of MIL-PRF-19500 and as specified herein. The following measurements shall be made in accordance with table I herein. Devices that exceed the limits of table I herein shall not be acceptable.

Screen (see	Measurement			
table IV of MIL-PRF-19500)	JANS level	JANTX and JANTXV levels		
(1) 3c	Required (see 4.3.2)	Required (see 4.3.2)		
9	h _{FE2} , I _{CBO2}	Not applicable		
11	I_{CBO2} ; h_{FE2} ; $\Delta I_{CBO2} = 100$ percent of initial value or 2 nA dc, whichever is greater; $\Delta h_{FE2} = 15$ percent change from initial value.	I _{CBO2} and h _{FE2}		
12	See 4.3.1	See 4.3.1		
13	Subgroups 2 and 3 of table I herein; $\Delta I_{CBO2} = 100$ percent of initial value or 2 nA dc, whichever is greater; $\Delta h_{FE2} = 15$ percent change from initial value.	Subgroup 2 of table I herein; $\Delta I_{CBO2} = 100$ percent of initial value or 2 nA dc, whichever is greater; $\Delta h_{FE2} = 15$ percent change from initial value.		

⁽¹⁾ Thermal impedance may be performed any time after sealing provided temperature cycling is performed in accordance with MIL-PRF-19500, screen 3 prior to this thermal test.

^{4.3.1 &}lt;u>Power burn-in conditions</u>. Power burn-in conditions are as follows: $T_A = Room$ ambient as defined in 4.5 of MIL-STD-750; $V_{CB} = 10$ -20 V dc; power shall be applied to achieve $T_J = 135^{\circ}C$ minimum and a minimum power dissipation = 75 percent of maximum rated P_T (see 1.3). NOTE: No heat sink or forced air cooling on the devices shall be permitted.

- 4.3.2 Thermal impedance ($Z_{\theta JX}$ measurements). The $Z_{\theta JX}$ measurements shall be performed in accordance with method 3131 of MIL-STD-750.
 - a. I_M measurement current......5 mA.
 - b. I_H forward heating current200 mA (min).
 - c. t_H heating time......25 30 ms.
 - d. t_{md} measurement delay time60 μs max.
 - e. V_{CE} collector-emitter voltage......10 V dc minimum(same as V_H).
 - f. V_H collector-emitter heating voltage ... 10 V (minimum).

The maximum limit for $Z_{\theta JX}$ under these test conditions are $Z_{\theta JX}$ (max) = 60°C/W. (UA and UB); 67°C/W (2N4029 and 2N4033).

- 4.3.3 <u>Screening (JANHC and JANKC)</u>. Screening of JANHC and JANKC die shall be in accordance with MIL-PRF-19500, "Discrete Semiconductor Die/Chip Lot Acceptance". Burn-in duration for the JANKC level follows JANS requirements; the JANHC follows JANTX requirements.
- 4.4 <u>Conformance inspection</u>. Conformance inspection shall be in accordance with MIL-PRF-19500 and as specified herein.
- 4.4.1 <u>Group A inspection</u>. Group A inspection shall be conducted in accordance with appendix E, table V of MIL-PRF-19500 and table I herein.
- 4.4.2 <u>Group B inspection.</u> Group B inspection shall be conducted in accordance with the tests and conditions specified for subgroup testing in table VIa (JANS) of MIL-PRF-19500 and 4.4.2.1 herein. Electrical measurements (end-points) and delta requirements shall be in accordance with group A, subgroup 2 and 4.5.2 herein: delta requirements only apply to subgroups B4, and B5. See 4.4.2.2 for JAN, JANTX, and JANTXV group B testing. Electrical measurements (end-points) and delta requirements for JAN, JANTX, and JANTXV shall be after each step in 4.4.2.2 and shall be in accordance with group A, subgroup 2 and 4.5.2 herein.
 - 4.4.2.1 Group B inspection, table VIa (JANS) of MIL-PRF-19500.

<u>Subgroup</u>	<u>Method</u>	<u>Condition</u>
B4	1037	$V_{CB} = 10 \text{ V dc.}$
B5	1027	$V_{CB} = 10 - 20$ V dc; $P_D \ge 75$ percent of maximum rated P_T (see 1.3). Option 1: 96 hours min, sample size in accordance with table VIa of MIL-PRF-19500, adjust T_A to achieve $T_J = +275^{\circ}C$ minimum. Option 2: 216 hours., sample size = 45, c = 0; adjust T_A to achieve $T_J = +225^{\circ}C$ minimum.

4.4.2.2 <u>Group B inspection, (JAN, JANTX and JANTXV)</u>. Separate samples may be used for each step. In the event of a group B failure, the manufacturer may pull a new sample at double size from either the failed assembly lot or from another assembly lot from the same wafer lot. If the new "assembly lot" option is exercised, the failed assembly lot shall be scrapped.

<u>Step</u>	Method	<u>Condition</u>
1	1039	Steady-state life: Test condition B, 340 hours, $V_{CB}=10$ - 20 V dc, power shall be applied to the device to achieve $T_J=+150^{\circ}C$ minimum, and a minimum of $P_D=75$ percent of maximum rated P_T as defined in 1.3 herein. $n=45$, $c=0$.
2	1039	The steady-state life test of step 1 shall be extended to 1,000 hours for each die design. Samples shall be selected from a wafer lot every twelve months of wafer production. Group B, step 2 shall not be required more than once for any single wafer lot. $n = 45$, $c = 0$.
3	1032	High- temperature life (non-operating), $T_A = +200^{\circ}C$, $t = 340$ hours, $n = 22$, $c = 0$.

- 4.4.2.3 <u>Group B sample selection</u>. Samples selected from group B inspection shall meet all of the following requirements:
 - For JAN, JANTX, and JANTXV samples shall be selected randomly from a minimum of three wafers (or from each wafer in the lot) from each wafer lot. For JANS, samples shall be selected from each inspection lot. See MIL-PRF-19500.
 - b. Must be chosen from an inspection lot that has been submitted to and passed group A, subgroup 2, conformance inspection. When the final lead finish is solder or any plating prone to oxidation at high temperature, the samples for life test (subgroups B4 and B5 for JANS, and group B for JAN, JANTX, and JANTXV) may be pulled prior to the application of final lead finish.
- 4.4.3 <u>Group C inspection</u>. Group C inspection shall be conducted in accordance with the tests and conditions specified for subgroup testing in table VII of MIL-PRF-19500, and in 4.4.3.1 (JANS) and 4.4.3.2 (JAN, JANTX, and JANTXV) herein for group C testing. Electrical measurements (end-points) and delta requirements shall be in accordance with group A, subgroup 2 and 4.5.2 herein; delta requirements only apply to subgroup C6.
 - 4.4.3.1 Group C inspection, table VII (JANS) of MIL-PRF-19500.

<u>Subgroup</u>	Method	Condition
C2	2036	Test condition E; (method 2036 not applicable for UA and UB devices).
C6	1026	1,000 hours at V_{CB} = 10 V dc; power shall be applied to achieve T_J = +150°C minimum and a minimum of P_D = 75 percent of maximum rated P_T as defined in 1.3.

4.4.3.2 Group C inspection, table VII (JAN, JANTX, and JANTXV) of MIL-PRF-19500.

<u>Subgroup</u>	<u>Method</u>	Condition
C2	2036	Test condition E; not applicable for UA and UB devices.
C6		Not applicable.

- 4.4.3.3 <u>Group C sample selection</u>. Samples for subgroups in group C shall be chosen at random from any inspection lot containing the intended package type and lead finish procured to the same specification which is submitted to and passes group A tests for conformance inspection. When the final lead finish is solder or any plating prone to oxidation at high temperature, the samples for C6 life test may be pulled prior to the application of final lead finish. Testing of a subgroup using a single device type enclosed in the intended package type shall be considered as complying with the requirements for that subgroup.
 - 4.5 Method of inspection. Methods of inspection shall be as specified in the appropriate tables and as follows.
- 4.5.1 <u>Pulse measurements</u>. Conditions for pulse measurement shall be as specified in section 4 of MIL-STD-750.
 - 4.5.2 Delta requirements. Delta requirements shall be as follows: 3/4/5/6/

Step	Inspection	MIL-STD-750		Symbol	Limit	Unit
	<u>1</u> / <u>2</u> /	Method	Conditions			
1.	Collector-base cutoff current	3036	Bias condition D, V _{CB} = 60 V dc	ΔI _{CB02} (1)	100 percent of initial value or 5 nA dc, whichever is greater.	
2.	Forward current transfer ratio	3076	$V_{CE} = 5 \text{ V dc};$ $I_{C} = 100 \text{ mA dc};$ pulsed see 4.5.1	Δh _{FE2} (1)	±25 percent change from initial reading.	

- 1/ See MIL-PRF-19500 for sampling plan.
- 2/ Devices which exceed the group A limits for this test shall not be acceptable.
- 3/ The delta measurements for table VIa (JANS) of MIL-PRF-19500 are as follows:
 - a. Subgroup 3, see table II herein, step 2.
 - b. Subgroups 4 and 5, see table II herein, step 2.
- 4/ The delta measurements for table VIb (JANTX and JANTXV) of MIL-PRF-19500 are as follows:
 - a. Subgroup 2, see table II herein, step 1.
 - b. Subgroups 3 and 6, see table II herein, step 1.
- 5/ The delta measurements for table VII of MIL-PRF-19500 are as follows:
 - a. Subgroup 6, see table II herein, step 1.

TABLE I. Group A inspection.

Inspection 1/	MIL-STD-750		Symbol	Lin	nits	Unit
	Method	Conditions		Min	Max	
Subgroup 1 2/						
Visual and mechanical inspection 3/	2071	n = 45 devices, c = 0				
Solderability 3/4/	2026	n = 15 leads, c = 0				
Resistance to solvents 3/ 4/ 5/	1022	n = 15 devices, c = 0				
Temp cycling $\underline{3}/\underline{4}/$ 1051 Test condition C, 25 cycles. r 22 devices, c = 0		Test condition C, 25 cycles. n = 22 devices, c = 0				
Heremetic seal <u>4/</u> Fine leak Gross leak	1071	n = 22 devices, c = 0				
Electrical measurements <u>4</u> /	1 1 1 1 7 1 1 1 1 1 1 1 1 1 1 1 1 1 1 1					
Bond strength 3/4/	2037	2037 Precondition $T_A = +250^{\circ}C$ at $t = 24$ hours or $T_A = +300^{\circ}C$ at $t = 2$ hours $n = 11$ wires, $c = 0$				
Subgroup 2						
Collector to base cutoff current	3036	Bias condition D; V _{CB} = 80 V dc pulsed (see 4.5.1)	I _{CBO1}		10	μA dc
Emitter to base cutoff current	3061	Bias condition D; V _{BE} = 5 V dc	I _{EBO1}		10	μA dc
Collector - base cutoff current	3036	Bias condition D; V _{CB} = 60 V dc	I _{CBO2}		10	nA dc
Collector - emitter cutoff current	3041	Bias condition A; $V_{BE} = 2.0 \text{ V dc}$; $V_{CE} = 60 \text{ V dc}$	I _{CEX1}		25	nA dc
Base emitter cutoff current	3061	Bias condition D; V _{BE} = 3.0 V dc	I _{EBO2}		25	nA dc
Forward-current transfer ratio	3061	$V_{CE} = 5.0 \text{ V dc}; I_{C} = 100 \mu\text{A dc}$	h _{FE1}	50		

See footnotes at end of table.

TABLE I. Group A inspection - Continued.

Inspection 1/	MIL-STD-750		Symbol	Limits		Unit
	Method	Conditions		Min	Max	
Subgroup 2 – Continued			h _{FE2}	100	300	
Forward-current transfer ratio	3076	$V_{CE} = 5.0 \text{ V dc}; I_{C} = 100 \text{ mA dc}$				
Forward-current transfer ratio	3076	V_{CE} = 5.0 V dc; I_{C} = 500 mA dc pulsed (see 4.5.1)	h _{FE3}	70		
Forward-current transfer ratio	3076	V _{CE} = 5.0 V dc; I _C = 1.0 A dc; pulsed (see 4.5.1)	h _{FE4}	25		
Collector – emitter saturated voltage	3071	I_C = 150 mA dc; I_B = 15 mA dc pulsed (see 4.5.1)	V _{CE(SAT)1}		0.15	V dc
Collector – emitter saturated voltage	3071	I_C = 500 mA dc; I_B = 50 mA dc; pulsed (see 4.5.1)	V _{CE(SAT)2}		0.50	V dc
Collector – emitter saturated voltage	3071	I_C = 1.0 A dc; I_B = 100 mA dc; pulsed (see 4.5.1)	V _{CE(SAT)3}		1.0	V dc
Base – emitter Saturated voltage	3066	Test condition A; $I_C = 150$ mA dc; $I_B = 15$ mA dc pulsed (see 4.5.1)	V _{BE(SAT)1}		0.9	V dc
Base - emitter Saturated voltage	3066	Test condition A; $I_C = 500 \text{ mA}$ dc; $I_B = 50 \text{ mA}$ dc; pulsed (see 4.5.1)	V _{BE} (SAT)2		1.2	V dc
Subgroup 3						
High-temperature operation:		T _A = +150°C				
Collector -base cutoff current	3036	Bias condition D; V _{CB} = 60 V dc	I _{CBO3}		25	μA dc
Low-temperature operation:		T _A = -55°C				
Forward-current transfer ratio	3076	$V_{CE} = 5.0 \text{ V dc}; I_{C} = 500 \text{ mA dc}$ pulsed (see 4.5.1)	h _{FE5}	30		

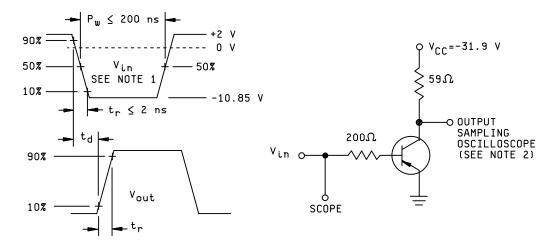
See footnotes at end of table.

TABLE I. Group A inspection - Continued.

Inspection 1/		MIL-STD-750	Symbol	Limits		Unit
Method		Conditions		Min	Max	
Subgroup 4						
Magnitude of common emitter small-signal short-circuit forward-current transfer ratio	3306	$V_{CE} = 10 \text{ V dc}; I_{C} = 50 \text{ mA dc};$ f = 100 MHz	h _{fe}	1.5	6.0	
Open circuit output capacitance	3236	$V_{CB} = 10 \text{ V dc}; I_E = 0$ $100 \text{ kHz} \le f \le 1 \text{ MHz}$	C _{obo}		20	pF
Input capacitance (output open-circuited) 3240		$V_{EB} = 0.5 \text{ V dc}; I_{C} = 0;$ 100 kHz \le f \le 1 MHz	C _{ibo}		80	pF
Pulse response						
On-time	3251	Test condition A; $I_C = 500$ mA dc; $I_{B1} = 50$ mA dc; (see figure 6)	t _d		15	ns
Rise time	3251	Test condition A; $I_C = 500$ mA dc; $I_{B1} = 50$ mA dc; (see figure 6)	t _r		25	ns
Storage time	3251	Test condition A; $I_C = 500$ mA dc; $I_{B1} = 50$ mA dc; (see figure 7)	t _s		175	ns
Fall time	3251	Test condition A; $I_C = 500$ mA dc; $I_{B1} = 50$ mA dc; (see figure 7)	t _f		35	Ns
Subgroups 5, 6, and 7						
Not applicable						

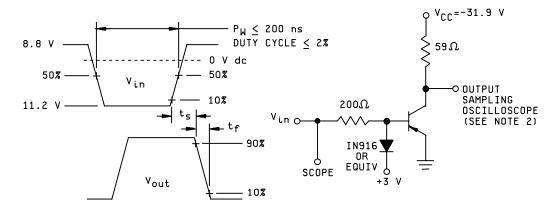
^{1/} For sampling plan see MIL-PRF-19500. 2/ For resubmission of failed subgroup A1, double the sample size of the failed test or sequence of tests. A failure in group A, subgroup 1 shall not require retest of the entire subgroup. Only the failed test shall be rerun upon submission.

^{3/} Separate samples may be used. 4/ Not required for JANS devices. 5/ Not required for laser marked devices.



- 1. The rise time (t_r) of the applied pulse shall be \leq 2.0 ns, duty cycle \leq 2 percent, and the generator source Z shall be 50 Ω .
- 2. Sampling oscilloscope: $Z_{IN} \ge 100 \text{ k}\Omega$; $C_{in} \le 12 \text{ pF}$, rise time(t_r) $\le 5 \text{ ns}$.

FIGURE 6. Delay and rise time, test circuit.



- 1. The rise time (t_r) of the applied pulse shall be \leq 20 ns, duty cycle \leq 2 percent, and the generator source impedance shall be 50Ω .
- 2. Sampling oscilloscope: $Z_{IN} \ge 100 \text{ k}\Omega$; $C_{in} \le 12 \text{ pF}$, rise time(t_r) $\le 5 \text{ ns}$.

FIGURE 7. Storage and fall time, test circuit.

5. PACKAGING

5.1 <u>Packaging</u>. Packaging shall prevent mechanical damage of the devices during shipping and handling and shall not be detrimental to the device. When actual packaging of materiel is to be performed by DoD personnel, these personnel need to contact the responsible packaging activity to ascertain requisite packaging requirements. Packaging requirements are maintained by the Inventory Control Points' packaging activity within the Military Department or Defense Agency, or within the Military Departments' System Command. Packaging data retrieval is available from the managing Military Departments' or Defense Agency's automated packaging files, CD-ROM products, or by contacting the responsible packaging activity.

6. NOTES

(This section contains information of a general or explanatory nature that may be helpful, but is not mandatory.)

- 6.1 Intended use. The notes specified in MIL-PRF-19500 are applicable to this specification.
- 6.2 Acquisition requirements. Acquisition documents must specify the following:
 - a. Title, number, and date of this specification.
 - b Issue of DoDISS to be cited in the solicitation (see 2.2.1).
 - c. The lead finish as specified (see 3.4.1).
 - d. Type designation and quality assurance level.
 - e. Packaging requirements (see 5.1).
- 6.3 Qualification. With respect to products requiring qualification, awards will be made only for products which are, at the time of award of contract, qualified for inclusion in Qualified Manufacturers' List (QML) whether or not such products have actually been so listed by that date. The attention of the contractors is called to these requirements, and manufacturers are urged to arrange to have the products that they propose to offer to the Federal Government tested for qualification in order that they may be eligible to be awarded contracts or orders for the products covered by this specification. Information pertaining to qualification of products may be obtained from Defense Supply Center, Columbus, ATTN: DSCC/VQE, P.O. Box 3990, Columbus, OH 43216-5000.
- 6.4. <u>Suppliers of JANHC and JANKC die.</u> The qualified JANHC and JANKC suppliers with the applicable letter version (example JANHCA2N4033) will be identified on the QPL.

Die ordering information				
PIN	Manufacturer			
	34156			
2N4033	JANHCA2N4033 JANKCA2N4033			

6.5 <u>Changes from previous issue</u>. Marginal notations are not used in this revision to identify changes with respect to the previous issue due to the extensiveness of the changes.

Custodians: Army - CR Navy - NW Air Force - 11 DLA - CC

Preparing activity: DLA - CC

(Project 5961-2386)

Review activities:

Army - AV Air Force - 19, 71, 99

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INSTRUCTIONS

- 1. The preparing activity must complete blocks 1, 2, 3, and 8. In block 1, both the document number and revision letter should be given.
- submitter of this form must complete blocks 4.5.6. and 7.

2. The submitter of this form must com	plete blocks 4, 5, 6, and 7.	
3. The preparing activity must provide a	a reply within 30 days from receipt of the form.	
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3. DOCUMENT TITLE SEMICONDUCTOR DEVICE, TRANS JAN, JANTX, JANTXV, AND JANS AND	SISTOR, PNP, SILICON, SWITCHING TYPES 2 D JANKC2N4033 AND JANHC2N4033	N4029, 2N4033, 2N4033UA, 2N4033UB,
4. NATURE OF CHANGE (Identify par	ragraph number and include proposed rewrite, if	possible. Attach extra sheets as needed.)
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DD Form 1426, Feb 1999 (EG)	Previous editions are obsolete	WHS/DIOR, Feb 99